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### A resistance change effect in perovskite CH<sub>3</sub>NH<sub>3</sub>PbI<sub>3</sub> films induced by ammonia

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The resistance of the perovskite  $CH_3NH_3Pbl_3$  film was found to decrease significantly in seconds when the film exposed in the  $NH_3$  atmosphere at room-temperature, and recover to its original value in seconds when out of  $NH_3$  environment.

Organometal halide perovskites such as  $CH_3NH_3PbX_3$  (X = Cl, Br, I) have recently attracted much attention as light-harvesting materials for solar cells,<sup>1-5</sup> owing to their appropriate direct bandgap, large absorption coefficient,<sup>6,7</sup> long carrier lifetime and high carrier mobility.<sup>8,9</sup> The power conversion efficiency of perovskite solar cells has been rapidly boosted from 3.8% to 20.1%.<sup>1,10</sup> In recent two years, organometal halide perovskites also showed attractive application prospect photodetectors,<sup>11,12</sup> light emitting diodes,<sup>13-15</sup> and lasers.<sup>16,17</sup> Generally this class of compounds very easily absorb polar gases and vapor, which is considered to be a critical factor detrimentally affecting the long-term stabilities of perovskite devices.<sup>18</sup> Interestingly, however, one can take advantage of this feature of these materials to extend their applications as gas sensors. Zhu's group found that the color of perovskite CH<sub>3</sub>NH<sub>3</sub>Pbl<sub>3</sub> (MAPbl<sub>3</sub>)/TiO<sub>2</sub> film changed from brown to colorless immediately (<1 s) when exposed in the NH<sub>3</sub> atmosphere, and turned back to the original color within seconds after removed from NH<sub>3</sub>, suggesting its application for NH<sub>3</sub> sensor. However, they also found that the perovskite MAPbl<sub>3</sub>/TiO<sub>2</sub> film exposed to NH<sub>3</sub> for a long period of time (tens of minutes) could not turn back to brown color when the NH<sub>3</sub> atmosphere removed.<sup>19</sup> The poor stability and repeatability will seriously hinder the application of perovskite in optical-based NH<sub>3</sub> sensors.

In this work, we investigated the resistance change of perovskite  $MAPbI_3$  film induced by  $NH_3$ . We found that the

resistance of the perovskite MAPbI<sub>3</sub> film was obviously reduced within seconds when the film was exposed in the resistance atmosphere and the film could return to the high resistance state within seconds after the NH<sub>3</sub> atmosphere was removed Our study indicated that a new phase has been produced afte the perovskite MAPbI<sub>3</sub> react with NH<sub>3</sub>, and the resistance of the new phase showed similar sensitive response to NH<sub>3</sub> a perovskite MAPbI<sub>3</sub>. These phenomena inspire the nev application of perovskite as electrical-based NH<sub>3</sub> sensors with higher stability than optical-based NH<sub>3</sub> sensors. Besides, the insight to the interacting of MAPbI<sub>3</sub> with the surrounding environment in our study could also inspire the work to improve the long-term stability of devices based on this class of perovskite materials.

MAPbl<sub>3</sub> film was fabricated by the one-step spin-coating method according to the work reported elsewhei a previously.<sup>20</sup> Briefly, FTO glass was patterned by laser cutting and cleaned with acetone, ethanol and deionized water respectively. Then the pre-cleaned FTO electrode was spin coated with the MAPbl<sub>3</sub> precursor solution (40 wt%, in N, N-dimethylformamide) at a rate of 2000 rpm for 30 s, followed by annealing at 100 °C for 15 min. The thickness of the a. prepared perovskite films was about 1  $\mu$ m (Fig. S1 ESI<sup>+</sup>). The resistance change of the MAPbl<sub>3</sub> film induced by NH<sub>3</sub> was measured in a Teflon chamber (50 mL) at room temperatul a (RT, around 25 °C). During the test, dry pure NH<sub>3</sub> (1 L min<sup>-1</sup>, and N<sub>2</sub> (2 L min<sup>-1</sup>) were injected into the chamber. The schematic diagram of the perovskite MAPbl<sub>3</sub> electrod structure and the test system is shown in Fig. 1(a).

Fig. 1(b) gives the I-V curves of the MAPbI<sub>3</sub> electrole exposed in the atmosphere of  $N_2$  (NH<sub>3</sub> OFF) and the m ed atmosphere of NH<sub>3</sub> and N<sub>2</sub> (NH<sub>3</sub> ON). We can see that, within the test bias voltage (-3 V to 3 V), the current through the MAPbI<sub>3</sub> film under NH<sub>3</sub> OFF was obviously smaller than the under NH<sub>3</sub> ON. This indicates that the resistance of the MAPb<sup>1</sup> film can be greatly decreased when the film is exposed in the NH<sub>3</sub> atmosphere. The sheet resistance of the films were als measured with four probe method before and after exposed in

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<sup>&</sup>lt;sup>+</sup>Electronic supplementary information (ESI) available: The cross section SEM image of the perovskite film, figure of sheet resistance measurement and resistance change induced by moisture. See DOI: 10.1039/ x0xx00000x

### COMMUNICATION



**Fig. 1** (a) Schematic diagram of the MAPbI<sub>3</sub> film structure and the resistance measurement set-up. (b) I-V curves of the MAPbI<sub>3</sub> film when the NH<sub>3</sub> ON and OFF at RT. (c) I-t curve of the MAPbI<sub>3</sub> film with the NH<sub>3</sub> switching ON and OFF at RT. The applied bias voltage is 1.5 V. (d) The enlarged view of the dash line rectangle area in the I-t curve, which shows the current rise and decay when the NH<sub>3</sub> switching ON and OFF.

the  $NH_3$  atmosphere. The results were shown in Fig. S2 (ESI<sup>+</sup>), which confirmed the resistance change of the film reduced by  $NH_3$ .

Fig. 1(c) shows the I-t curve of the MAPbI<sub>3</sub> film with the NH<sub>3</sub> flow switched ON and OFF. The current was tested under the bias voltage of 1.5 V. From the I-t curve we can see the current through the film under NH<sub>3</sub> ON was obviously greater than that under NH<sub>3</sub> OFF. At the beginning stage (before ~200 s) of the test, the measured currents under NH<sub>3</sub> ON and NH<sub>3</sub> OFF both decreased obviously. In order to explain this phenomenon, we speculate that there are two kinds of processes occurring when MAPbl<sub>3</sub> react with NH<sub>3</sub>: one is reversible, such as adsorption or intercalation; and the other is an irreversible process. Reversible reaction is the reason why the resistance of the film can repeatedly response to the switch of NH<sub>3</sub>: when the film is exposed in the NH<sub>3</sub> atmosphere, the NH<sub>3</sub> molecules will be adsorbed by the film or inserted in the space of the crystal lattice, and the film shows relatively low resistance; when the NH<sub>3</sub> atmosphere is removed, the NH<sub>3</sub> molecules adsorbed or inserted in the film will be quickly released, and the film returns to the relatively high resistance state. Meanwhile, NH<sub>3</sub> can also irreversibly transform perovskite MAPbl<sub>3</sub> into a new phase or compound (signed as MAPbl<sub>3</sub>+NH<sub>3</sub>). In the same environment (NH<sub>3</sub> ON or OFF), the resistance of the MAPbl<sub>3</sub>+NH<sub>3</sub> film is higher than the pristine perovskite MAPbI<sub>3</sub> film, so at the beginning stage of the test, the measured currents when  $\mathsf{NH}_3$  is ON and OFF decrease obviously. At the last stage (after ~200 s) of the test, when the perovskite MAPbI<sub>3</sub> film is completely transformed into MAPbl<sub>3</sub>+NH<sub>3</sub>, both of the currents when the NH<sub>3</sub> is ON and OFF become relatively stable.

Both the pristine  $MAPbI_3$  perovskite film and the newly generated  $MAPbI_3+NH_3$  film show quick response to the  $NH_3$ .



Page 2 of 4

Fig. 2 Transmittance spectra (left) and the color change (righ ) of the perovskite  $MAPbl_3$  film before (0 s) and after exposed in  $NH_3$  atmosphere for 5 s and 50 s.

Fig. 1(d) shows that when the  $NH_3$  switch from OFF to ON, the current increases from below 10 nA to the saturation current (~110 nA) in about 3.0 s. When the  $NH_3$  is OFF, the current car recover to below 10 nA in about 4.5 s. This is a very short response time for  $NH_3$  sensor, especially for sensors working a RT.<sup>21,22</sup> These results inspire the potential application in fast response  $NH_3$  sensor of the MAPbI<sub>3</sub> film. It is worth noting this sensor is based on the change of electrical property, which is of more practical significance than that based on the change of optical property, because electrical property is much easier to be detected then optical property.

The above proposed processes occurring when the MAPble film exposed in NH<sub>3</sub> was also reflected in the color change the film induced by NH<sub>3</sub>. Previous work showed that the color of the MAPbl<sub>3</sub>/TiO<sub>2</sub> film changed reversibly when exposed 🕠 NH<sub>3</sub>, and the reversibility was destroyed when the exposure time increased to tens of minutes.<sup>19</sup> We found that, for the second sec NH<sub>3</sub> induced color change of the pure MAPbI<sub>3</sub> films, the reversibility was completely destroyed in a shorter exposure time (<50 s). Fig. 2 shows the optical characterizations of the pristine perovskite MAPbl<sub>3</sub> film and the recovered film after exposed in NH<sub>3</sub> for 5 s and 50 s. The right frame shows the digital photographs, the left frame shows the transmittance spectra. The pristine perovskite MAPbl<sub>3</sub> film displays brow color. The transmittance spectrum tells that the perovski MAPbl<sub>3</sub> film keeps low transmittance below 755 nm, and increases sharply at 755 nm, which agree with the band gap ( perovskite MAPbl<sub>3</sub>. When exposed in NH<sub>3</sub> atmosphere for about 5 s, the color of the film could not be completely restored to the original brown but changed to light brown after the NH<sub>3</sub> atmosphere was removed. It can be seen that. compared to that of the pristine perovskite MAPbl<sub>3</sub> film, the transmittance of the film after exposed in NH<sub>3</sub> for 5 s increase a across the entire visible region. In addition to 755 nm, and absorption edge at around 500 nm appeared, indicating that a new phase appeared after the film was exposed in NH<sub>3</sub> for 5 s. When exposed in NH<sub>3</sub> for a longer period of time (about 50 ,

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**Fig. 3** XRD patterns (a, c, e) and SEM images (b, d, f) of the perovskite MAPbl<sub>3</sub> film before (a, b) and after exposed in the NH<sub>3</sub> atmosphere for 5 s (c, d) and 50 s (e, f).

the film kept light yellow color after the NH<sub>3</sub> atmosphere was removed. The film showed single absorption edge at around 500 nm and homogeneous high transmittance at the longer wavelength region, suggesting that the perovskite MAPbI<sub>3</sub> has been transformed into the new phase absolutely. Though the color change in one sample caused by the irreversible reaction of perovskite MAPbI<sub>3</sub> and NH<sub>3</sub> is unrepeatable, the resistance change is repeatable because the new product generated from the irreversible reaction also shows similar NH<sub>3</sub> induced resistance change character to perovskite MAPbI<sub>3</sub>. Therefore, this electrical-based NH<sub>3</sub> sensor shows better repeatability and stability compared to optical-based one.

To further understand the phase transformation and the morphology change induced by NH<sub>3</sub> on the perovskite MAPbI<sub>3</sub> film, we carried out X-ray diffraction (XRD) measurements and morphology characterizations on the pristine perovskite MAPbl<sub>3</sub> film and that after exposed in the NH<sub>3</sub> atmosphere for different period of time. The results were exhibited in Fig. 3. The XRD pattern and scanning electron microscopy (SEM) image of the pristine perovskite film were shown in Fig. 3(a) and (b). The XRD pattern indicates that  $\mathsf{MAPbI}_3$  has a tetragonal perovskite structure (peaks marked with squares). The diffraction peaks at about 14.02 19.94, 28.42, 31.78, 40.48 and 43.04 degree correspond to the reflections from (110), (112), (220), (310), (224) and (314) crystal planes respectively. No Pbl<sub>2</sub> and other impurity peaks other than the ones attributed to FTO (marked with circles) are observed. SEM image in Fig. 3(b) shows that the pristine perovskite MAPbl<sub>3</sub>

### COMMUNICATION

film is rough and continuous, which shows the sam morphology as previously reported.<sup>20</sup> After exposed in the NH atmosphere, a new phase appears in the perovskite MAPb film. The XRD pattern in Fig. 3(c) shows that, after expose NH<sub>3</sub> for 5 s, intensities of all the diffraction peaks belonging 🚺 tetragonal perovskite structure are reduced and new diffraction peaks (marked with triangles) belonging to a ne / phase (MAPbl<sub>3</sub>+NH<sub>3</sub>) appears. Meanwhile, the morphology of the film was reconstructed and the coverage and smoothne s were increased (Fig. 3(d)), which was similar to the phenomenon when fumigated in DMF vapor as we reported previously.<sup>23</sup> The reconstruction of the film may results from the difference of the crystal structure before and after the reaction with NH<sub>3</sub>. After exposed in NH<sub>3</sub> for a longer period e time (about 50 s), the film transformed into the new phas completely (Fig. 3(e)). And the morphology of the film change obviously: the roughness increased and the cover decreased greatly (Fig. 3(f)). The discontinuous of the film may be an important reason of the greater resistance of MAPbI<sub>3</sub>+NH<sub>3</sub> film compared to the pristine perovskite MAPbI<sub>3</sub> film.

In addition to NH<sub>3</sub>, we have also studied the resistance change of perovskite MAPbl<sub>3</sub> film induced by moisture. Fig. S3 (ESI<sup>+</sup>) shows the I-V curves and I-t curve of the perovskit a MAPbl<sub>3</sub> film in dry N<sub>2</sub> and air with a relative humidity (RH) of about 50% at RT. The results indicate that a similar resistance change effect also can be induced by moisture in perovskit a MAPbl<sub>3</sub>.

In conclusion, we have investigated the resistance change the perovskite MAPbI<sub>3</sub> film induced by NH<sub>3</sub>. It was found that when the perovskite MAPbl<sub>3</sub> film was exposed to NH<sub>3</sub> th current through the film was greatly improved within seconds. When the NH<sub>3</sub> environment was removed, the current was decreased to the original value within seconds. XRD pattern and SEM images showed that when exposed in NH<sub>3</sub> perovskite MAPbI<sub>3</sub> gradually transformed to a new phase and morphology of the film changed significantly. The resistance of this new material was sensitive to NH<sub>3</sub> as that of perovskite MAPbl<sub>3</sub>. The results of this study imply that MAPbl<sub>3</sub> cou potentially be used as room-temperature-working NH<sub>3</sub> senso with fast response time. Meanwhile, understanding ho perovskites MAPbl<sub>3</sub> interact with the surrounding environmer is of great significance to improve the stability of the perovskite solar cells.

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Page 4 of 4